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## APPLICANTS

Klaus Breitschwerdt, Filderstadt, GERMANY;  
 Bernd Kutsch, Konz, GERMANY;  
 Franz Laermer, Weil Der Stadt, GERMANY;

\*\* CONTINUING DATA \*\*\*\*\* NONE IV

\*\* FOREIGN APPLICATIONS \*\*\*\*\* YES IV  
 GERMANY 102 49350.2 10/23/2002

IF REQUIRED, FOREIGN FILING LICENSE GRANTED \*\*  
 01/22/2004

Foreign Priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no	STATE OR COUNTRY GERMANY	SHEETS DRAWING 9	TOTAL CLAIMS 5	INDEPENDENT CLAIMS 4
35 USC 119 (a-d) conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no <input type="checkbox"/> Met after Allowance				
Verified and Acknowledged Examiner's Signature _____ Initials _____				

## ADDRESS

26646

## TITLE

Device and method for anisotropic plasma etching of a substrate, particularly a silicon element

<b>FILING FEE RECEIVED</b> 986	FEES: Authority has been given in Paper No. _____ to charge/credit DEPOSIT ACCOUNT No. _____ for following:	<input type="checkbox"/> All Fees
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